

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant	:	SOPHIE ET AL.) Group Art Unit 2813
Appl. No.	:	09/975,466	I hereby certify that this correspondence and all marked attachments are being
Filed	:	October 9, 2001) deposited with the United States Postal) Service as first-class mail in an envelope addressed to: United States Patent and) Trademark Office, P.O. Box 2327,
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			Adeel S. Akhtar, Reg. No. 41,394
Examiner	:	Kielin, E.	1
		Amendment and Response to	RECEIVED JAN 15 2003 ECHNOLOGY CENTER
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P.O. Box 232	7		VE CEF
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Dear Sir:		•	280

The present paper is submitted in response to the Office Action mailed on October 15, 2002. Applicants respectfully request that the Examiner enter the following amendments and consider the subsequent remarks.

In the Claims

Please cancel Claim 29.

Please amend Claims 1, 5, 8 and 28 to read as follows:

1. (Amended) A process for producing an integrated circuit comprising reducing copper oxide on a substrate by exposure to one or more stable organic reducing agents prior to deposition of a layer comprising silicon carbide.

5. (Amended) The process of Claim 4, wherein the organic reducing agent is selected from the group consisting of primary alcohols, secondary alcohols, tertiary alcohols, polyhydroxyalcohols, cyclic alcohols, and halogenated alcohols.